

## EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	44137	plasma adj cvd or plasma adj chemical	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/10/21 22:12
L2	4630	(plasma adj cvd or plasma adj chemical) near6 (silicon adj oxide)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/10/21 22:27
L3	2367	l2 and (tft or thin adj film adj transistor)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/10/21 22:30
L4	2057	l3 and glass adj substrate	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/10/21 22:30
L5	2	("5147826"   "5275851").PN.	US-PGPUB; USPAT; USOCR	OR	ON	2007/10/22 00:32